

CORRECTION

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5478**Correction: Facile, wafer-scale compatible growth of ZnO nanowires *via* chemical bath deposition: assessment of zinc ion contribution and other limiting factors**Yu-Chen Huang, Junze Zhou, Komla Nomenyo, Rodica Elena Ionescu,
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rsc.li/nanoscale-advancesCorrection for 'Facile, wafer-scale compatible growth of ZnO nanowires *via* chemical bath deposition: assessment of zinc ion contribution and other limiting factors' by Yu-Chen Huang *et al.*, *Nanoscale Adv.*, 2020, DOI: 10.1039/d0na00434k.

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